

Origin of Doping in Quasi-Free-Standing Graphene on Silicon Carbide

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We explain the robust *p*-type doping observed for quasi-free-standing graphene on hexagonal silicon carbide by the spontaneous polarization of the substrate. This mechanism is based on a bulk property of SiC, unavoidable for any hexagonal polytype of the material and independent of any details of the interface formation. We show that sign and magnitude of the polarization are in perfect agreement with the doping level observed in the graphene layer. With this mechanism, models based on hypothetical acceptor-type defects as they are discussed so far are obsolete. The *n*-type doping of epitaxial graphene is explained conventionally by donorlike states associated with the buffer layer and its interface to the substrate that overcompensate the polarization doping.

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The basis for the unique electronic and optical properties of graphene is the linear dispersion relation of the π electrons, which is responsible for Dirac-type quasiparticles with many unusual properties. The band structure in the relevant energy range is made up by double cones in the corners of the two-dimensional hexagonal Brillouin zone; their opening angle is determined by the slope $v_F = \frac{d\omega}{dk}$ of the dispersion relation called the Fermi velocity, which is an intrinsic material parameter. The origin of these so-called Dirac cones defines the Fermi energy in an isolated and intrinsic graphene layer. At finite temperatures, the reservoir of mobile charge carriers is due to thermal excitation of equal concentrations n_0 and p_0 of electrons and holes. Evaluation of the Fermi statistics yields a value of $n_0 = \frac{\pi k_B^2}{6\hbar v_F} T^2$ for this intrinsic charge carrier concentration at temperature T where k_B and \hbar are the Boltzmann and Planck constants, respectively [1]. For room temperature, this amounts to $n_0 = 6.1 \times 10^{10} \text{ cm}^{-2}$ when $v_F = 1.1 \times 10^6 \text{ ms}^{-1}$ is taken for the Fermi velocity [2,3].

Epitaxial graphene on hexagonal silicon carbide is never found to follow this expectation [4]. Graphene on SiC(0001) usually reveals a pronounced *n*-type conductivity with a Fermi level position about 0.45 eV above the Dirac energy and corresponding electron concentrations of $1.2 \times 10^{13} \text{ cm}^{-2}$, i.e., a value more than 2 orders of magnitude larger than n_0 . For 6H-SiC(0001) the band alignment between this substrate material and the graphene layer is asymmetric with the Dirac energy 0.75 eV below the SiC conduction band minimum (CBM) and 2.25 eV above the valence band maximum (VBM).

The *n*-type character of the graphene can be explained by donorlike states at the SiC/graphene interface. This interface is sketched in Fig. 1(a) along with a band diagram which will be discussed below. The graphene layer is sitting on top of a buffer layer that intimately resembles the surface layer of the so-called $(6\sqrt{3} \times 6\sqrt{3})R30^\circ$ recon-

struction of SiC(0001) that is almost commensurate with the graphene lattice [5]. The buffer layer is partially bound to the silicon atoms of the substrate and is considerably distorted as compared to graphene. Photoelectron spectroscopy shows surface states that can be associated with carbon or silicon dangling bonds superimposed on a broad density of states for the buffer layer that extends up to the

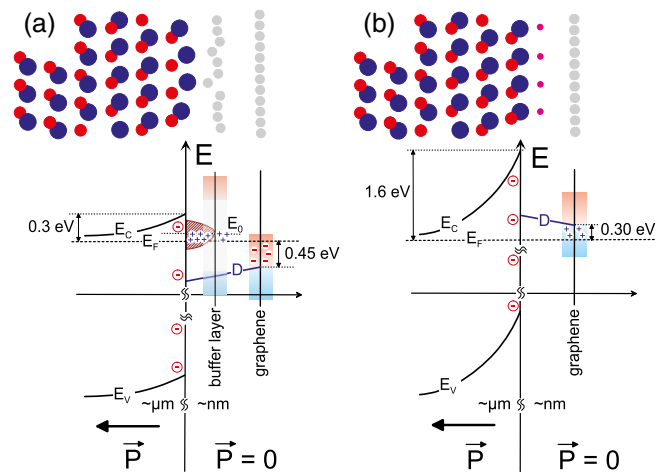


FIG. 1 (color online). Sketch and schematic band diagram for the epitaxial (a) and the quasi-free-standing (b) graphene interface with 6H-SiC(0001). Large and small circles represent silicon and carbon atoms, respectively, and the very small circles in (b) stand for hydrogen. The polarization vector inside and outside of the SiC is indicated at the bottom of the figure. Note that the negative polarization charge associated with the discontinuity of the polarization across the interface is not a real charge but a pseudo charge. In order to discern pseudo charge from real charge, it is marked by circles. It is not linked to electrons in real quantum-mechanical states (e.g., band states or defects). D sketches the electrostatic potential between the SiC surface and the graphene layer anchored at the Dirac energy in the graphene layer. For the band bending, information from photoelectron spectroscopy [24] has been taken into account.

Fermi level [5]. The complete ensemble of electronic states associated with the buffer layer and the SiC surface can be combined in an interface density of states with a charge neutrality level E_0 as shown schematically in the band diagram of Fig. 1(a). The n -type character of epitaxial graphene on SiC(0001) is most plausibly explained by electron transfer from these interface density of states to the graphene layer.

We should mention at this point that Kopylov *et al.* [6] have recently discussed this type of doping for monolayer and bilayer graphene. In addition, they discuss an alternative mechanism based on classical donors in the SiC substrate. However, in order to explain electron densities as measured in epitaxial graphene, a bulk doping level of more than 10^{19} cm $^{-3}$ is needed, which is incompatible with the type of SiC substrates commonly used. Moreover, the doping mechanism changes and is even inverted when the interface between SiC and graphene is passivated by hydrogen (see below). Both arguments suggest that interface rather than bulk states act as donors. We note in passing a very asymmetric alignment of the charge neutrality level E_0 of the interface density of states which is around 0.3 eV below the CBM and 2.7 eV above the VBM of 6H-SiC.

The situation becomes even more mysterious when a quasi-free-standing monolayer graphene (QFMLG) on hexagonal SiC(0001) is prepared. This hetero system forms when the carbon-rich ($6\sqrt{3} \times 6\sqrt{3}$) $R30^\circ$ reconstructed top layer of the SiC(0001) surface is delaminated by hydrogen intercalation [7]. With this technique, the carbon–silicon bonds to the substrate are released and the resulting silicon dangling bonds are saturated by hydrogen with remarkable perfection [8]. The Si–H bonds are electronically inactive, and in principle a defect-free interface between SiC and graphene is expected. Consequently, charge transfer to the graphene layer is now restricted to the depletion of the bulk doping of SiC, which is insufficient for any substantial doping as has been argued above. Hence, for the n -type and semi-insulating substrate material usually adopted for quasi-free-standing graphene on SiC(0001), very little n -type doping of the graphene layer by the substrate and a Fermi level in close vicinity of the Dirac energy is expected. The experimental observation, however, is the exact opposite: instead of mild n -type doping QFMLG on 6H-SiC(0001) exhibits a strong p -type conductivity with the Fermi level 0.30 eV below the Dirac energy and hole densities of about 5.5×10^{12} cm $^{-2}$, i.e., comparable to the electron densities observed for the epitaxial graphene. A mechanism along the classical lines would require a reservoir of acceptorlike defects now of a comparable capacity, although the interface is passivated by the hydrogen termination of the substrate. All classical models, e.g., involving the antibonding orbitals of Si–H bonds or acceptorlike hypothetical defects of this interface as doping reservoir, are implausible. The question, where

the robust p -type doping of hydrogen-intercalated graphene on hexagonal SiC comes from, is therefore a mystery so far and the unraveling of this mystery is the main subject of this Letter.

We suggest that the intrinsic spontaneous polarization of hexagonal SiC is responsible for the p -type doping of the quasi-free-standing graphene layer on top of it. To elucidate this mechanism somewhat, let us briefly reconsider (i) Coulomb’s fundamental law of electrodynamics $\vec{\nabla} \cdot \vec{D} = \rho$ linking the dielectric displacement \vec{D} to the space charge density ρ and (ii) the macroscopic linear relation between electric field \vec{E} and dielectric displacement in matter:

$$\vec{D} = \epsilon_0 \vec{E} + \vec{P} = \epsilon_0 \vec{E} + \vec{P}_0 + \chi \epsilon_0 \vec{E} = \epsilon_0 (1 + \chi) \vec{E} + \vec{P}_0. \quad (1)$$

Here, ϵ_0 is the vacuum permeability, $\chi = 1 - \epsilon$ the electric susceptibility, and \vec{P} the dipole density or polarization in the material under consideration which may have a spontaneous \vec{P}_0 and a field-induced component $\chi \epsilon_0 \vec{E}$. If we apply both equations to a layer stack system of two materials with dielectric constants ϵ_1 and ϵ_2 , the change $\Delta(\epsilon E) = \epsilon_2 E_2 - \epsilon_1 E_1$ of the weighted (normal) electric field components across the interface can be calculated, yielding

$$\Delta(\epsilon \epsilon_0 E) = \sigma - \Delta P_0. \quad (2)$$

For nonpyroelectric materials, P_0 is zero and Eq. (2) reduces to the familiar relation between the field change and the integrated space charge density σ (in units of charge per area) which holds for any arbitrarily selected range of the layer stack system. When pyroelectrics such as the hexagonal polytypes of SiC are involved, however, Eq. (2) shows that a difference in spontaneous polarization across an interface has the same effect as a negative sheet charge at the interface. Thus, $-\Delta P_0$ can be associated with a pseudo charge that we may call polarization charge in the following.

Although becoming important at interfaces only, the spontaneous polarization is a bulk property of the materials involved, and its change across a specific interface is independent of any structural or geometric details of that interface. Specifically, when a slab of pyroelectric material is embedded between nonpyroelectric layers—vacuum may also serve as the latter—the two surfaces inevitably carry a polarization charge with identical magnitude and opposite sign on the two interfaces that is an intrinsic bulk property of the pyroelectric material. For any electronic material brought into contact with the pyroelectric, this polarization charge is fully equivalent to a sheet of charged dopants on the pyroelectric side of the interface, however, without the necessity of any real quantum-mechanical states associated with those charges. We will show in the following that sign and magnitude of the spontaneous

polarization of 6H-SiC(0001) is perfectly consistent with the acceptor concentration needed to explain the p -type conductivity of H-intercalated graphene on that surface.

As already indicated above, spontaneous polarization is an intrinsic feature of all polytypes of SiC except for cubic 3C SiC. For the classical semiconductors Si, Ge, GaAs, or diamond, this feature is missing due to the cubic symmetry of the material, and therefore it is not considered at hetero interfaces of these semiconductors. It plays an important role, however, in the device physics of GaN and its derivatives, which are of wurtzite, i.e., hexagonal crystal structure [9]. Amazingly, it is very difficult to address it by experiment. It essentially leads to the polarization charges discussed above on the polar surfaces of the semiconductor compounds, which are usually compensated completely or in part by internal charge formation due to depletion or accumulation of charge carriers or by external buildup of ionic charge on the surfaces. Only the *modulation* of the polarization charge at a surface upon an external perturbation such as strain, temperature variation, or the presence of optical phonons can be measured [10–12] but not its base value. As a consequence, no experimental data are available for the polarization of any hexagonal semiconductor crystal. In order to discuss the polarization of SiC polytypes, we are therefore restricted to theoretical results.

However, for theory also, spontaneous polarization is conceptually difficult to address. The reason is that for any model with periodic boundary conditions, the dipole density $\vec{P} = \frac{1}{V} \int \vec{r} \cdot \rho(\vec{r}) dV$ of a system is ill-defined since it depends on the arbitrary choice of the unit-cell boundaries over which it is evaluated. Although the charge density $\rho(\vec{r})$ alone can be quite reliably and accurately determined by modern density functional techniques, the direct evaluation of the polarization is impossible. A breakthrough on this route was achieved by Posternak *et al.* in 1990 for BeO [13,14]. They constructed a periodic arrangement with a supercell containing a certain number of double layers of the wurtzite form together with a number of double layers of the zinc blende form. The latter one has zero polarization by symmetry. When calculating the potential along this periodic superstructure by density functional theory (DFT), the Born–von Kármán boundary conditions automatically eliminate the average electric field. However, the discontinuity of this field at the boundaries between the wurtzite and the zinc blende slab is independent of this artifact. This field discontinuity can directly be translated by (2) to the change in polarization. Because P_0 is known to be zero in the zinc blende slabs, P_0 can be evaluated by this trick for the wurtzite parts of the heterostructure. This quite ingenious approach was later taken by Qteish, Heine, and Needs [15,16] to calculate the spontaneous polarization of various SiC polytypes by density functional theory. They presented results for 2H (wurtzite), 6H, and 8H SiC.

Part of the spontaneous polarization can be ascribed to the relative elongation of the longitudinal Si–C bonds

along the \vec{c} axis and the contraction of the bonds transverse to it. For the wurtzite crystal structure (2H-SiC) with only two double layers in the unit cell, this distortion is characterized by the longitudinal bond length in units of the hexagonal lattice parameter \vec{c} , denoted as internal parameter u . When bond lengths and angles are chosen the same as in the cubic polytype (zinc blende) and only the stacking sequence is changed from staggered to eclipsed, the so-called ideal wurtzite structure with $u = 3/8$ is achieved. The projection of the transverse bonds on the \vec{c} axis is then $1/8c$, and since they are three times as many as the longitudinal bonds and point backwards relative to them, a simple geometric evaluation of the dipole density based on equally polarized bonds results in zero. In real cases, the internal parameter u for wurtzite alloys is usually between 0.2 and 2% larger than $3/8$ [17]. By taking only this purely geometric effect into account, a negative polarization (polarization vector opposing the conventional \vec{c} -axis direction) for hexagonal SiC corresponding to negative effective polarization charge on the Si-terminated (0001) surface is expected (see Fig. 1). However, even when this geometric relaxation is suppressed in DFT calculations by choosing all Si–C bond lengths identical in the hexagonal as well as in the cubic slabs of the model system (i.e., modeling the ideal wurtzite structure or its analogue), the loss of the cubic symmetry alone induces a relaxation of the space charge density with a contribution to the polarization that has the same sign but an even larger magnitude than the ionic relaxation contribution for 2H-SiC. ($-3.33 \times 10^{-2} \text{ C/m}^2$ compared to $-0.99 \times 10^{-2} \text{ C/m}^2$) [16,18]. This is quite in contrast to wurtzite BeO that has first been studied as a pyroelectric model substance [13]. Here, the geometric contribution to the polarization is the dominating one.

Unfortunately, and probably due to the computational demand of an *ab initio* and self-consistent quantum-mechanical modeling, only the 2H polytype of SiC with the smallest unit cell has been treated by the approach outlined above [16]. For 6H and 8H SiC, the spontaneous polarization was only calculated for an idealized hexagonal crystal structure with bond lengths and angles like in cubic SiC. The contribution of the ionic relaxation of the real polytypes relative to this structure is thus not included in the calculations. We may take the ratio c/a of the longitudinal and transverse hexagonal lattice parameters as relative measure for this ionic relaxation. It deviates from the corresponding values for the idealized structures by +0.49% for 2H SiC, +0.15% for 4H SiC, and +0.16% for 6H SiC [19]. The effect of ionic relaxation is thus about 3 times larger in 2H SiC than in the other polytypes, and since it contributes only 23% to the spontaneous polarization, even in the former case we may neglect it within the uncertainties of the calculations for 4H and 6H polytypes. For 6H SiC adopted usually as a substrate for quasi-free-standing graphene, the spontaneous polarization

then is $P_0 = -9.49 \times 10^{-3} \text{ C/m}^2$. As outlined above, this value is equivalent to a sheet of negatively charged donors on the Si face of the substrate with density $|P_0|/e = 5.9 \times 10^{12} \text{ cm}^{-2}$. This deviates by less than 10% from the hole density in the quasi-free-standing graphene layer measured on top of it (see above).

In a more recent calculation by Brandino *et al.* [20], the spontaneous polarization of SiC polytypes is revisited by a full quantum-mechanical treatment based on the work of Resta [21]. The results for 2H and 4H SiC are the same as those obtained by Qteish *et al.* [15,16] within 15%. For 6H SiC they find a value of $P_0 = -1.5 \times 10^{-2} \text{ C/m}^2$, i.e., about 50% larger than the value cited by Qteish *et al.* and corresponding to a negative charge density of $|P_0|/e = 9 \times 10^{12} \text{ cm}^{-2}$.

It should be mentioned at this point that Davydov and Troshin [22] have reviewed in 2007 the calculations of spontaneous polarization in SiC polytypes performed by different methods. They find a considerable scatter of the results that ranges for 2H SiC from -1.11 to $-4.32 \times 10^{-2} \text{ C/m}^2$. This indicates a substantial uncertainty also for the theoretical value of 6H SiC cited above. The agreement between the graphene hole density and the polarization calculated by Qteish *et al.* [15,16] is therefore somewhat fortuitous.

We conclude that spontaneous polarization of the hexagonal SiC substrate is directly responsible for the doping of quasi-free-standing graphene on its (0001) surface. The spontaneous polarization creates a pseudo-acceptor layer that is fully equivalent to real acceptors. Being a bulk property of the substrate, it constitutes an invariant pseudo-sheet charge density only characteristic for the respective hexagonal polytype of the substrate material. We have illustrated this doping mechanism of quasi-free-standing graphene on hexagonal SiC(0001) in the band diagram of Fig. 1(b).

The pseudo-polarization charge will be present for epitaxial graphene layers as well, but in this case it is obviously overcompensated by doping due to the interface density of states as explained above. Thus, when the spontaneous polarization of the substrate is properly taken into account, this density of states must account for both $-P_0/e$ and the observed electron density n in the epitaxial graphene layer.

The SiC substrates used in the experiment [8] were semi-insulating, i.e., with doping concentrations smaller than 10^{14} cm^{-3} . The areal charge density in the depletion layer of the SiC substrate associated with the band bending indicated in the figure is for such material in all cases smaller than $5 \times 10^{10} \text{ cm}^{-2}$. This is less than 1% of the pyroelectric pseudocharge or the areal charge density in graphene, and we have therefore omitted this charge in the band diagrams of Fig. 1 where the total negative and positive charge count of the interface is balanced.

There are a number of obvious tests of the polarization doping model suggested here: (i) preparing quasi-free-

standing graphene with a defect-free interface on the carbon-terminated faces of the hexagonal SiC substrates should lead to n -type doping; (ii) on cubic SiC it should lead to undoped graphene layers; and (iii) varying the hexagonality of the SiC polytype should increase the doping level proportionally since the spontaneous polarization is mainly induced at the inversion of the stacking sequence of the double layers [16]. For 4H-SiC, for example, the polarization is expected to be 6/4 times larger than that for 6H-SiC. For most of these tests, the preparation of the corresponding defect-free interfaces has not been realized to date. Only for the silicon terminated surface of 3C-SiC, Coletti *et al.* [23] have recently reported on quasi-free-standing graphene. In fact, the p -type doping as observed for the 6H-SiC is absent, and a mild n -type doping with an electron density of about $1.3 \times 10^{12} \text{ cm}^{-2}$ is found instead that can easily be explained by residual defects at the interface. We interpret the vanishing of the p -type character for QFMLG when going from the hexagonal 6H to the cubic 3C polytype as a very strong argument in support of the polarization doping model suggested in this Letter.

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